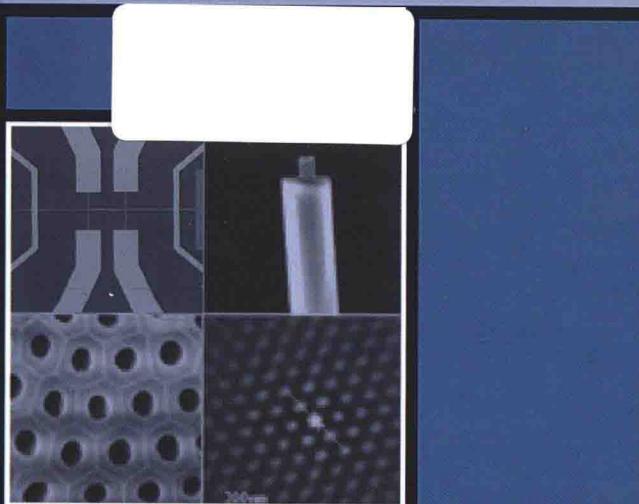


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Magnetic Nano- and Microwires

Design, Synthesis,
Properties and Applications

Edited by Manuel Vázquez

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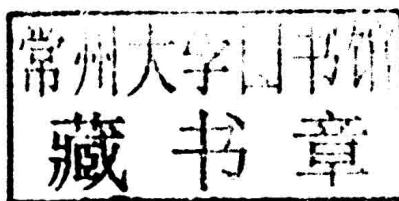
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